

**REMARKS/ARGUMENTS**

By this amendment, claim 1 is cancelled and claim 5 is amended. Claim 5 is amended to exclude oxalic acid as the acid. Claims 11-24 are cancelled as being drawn to the non-elected invention. Applicants acknowledge allowance of claims 2-4 and 7-10.

The Office Action rejected claims 1 and 5-6 under Section 102(b) as being anticipated by Ina et al. Claim 5 recited that the third polishing composition includes acid or alkali, wherein the acid includes at least one acid selected from the group consisting of nitric acid, hydrochloric acid, lactic acid, phosphoric acid, sulfuric acid, acetic acid, citric acid, tartaric acid, malonic acid, succinic acid, maleic acid, and fumaric acid, and wherein the alkali includes at least one alkali selected from the group consisting of potassium hydroxide, ammonium hydroxide, and sodium hydroxide. In contrast, the Ina et al. patent does not disclose or suggest the features recited in claim 5. Therefore, claim 5 is not anticipated. Withdrawal of the rejection under Section 102(b) is respectfully requested.

If there are any remaining issues preventing allowance of claims 2-10 that may be clarified by telephone, the Examiner is requested to call the undersigned.

Respectfully submitted,



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